

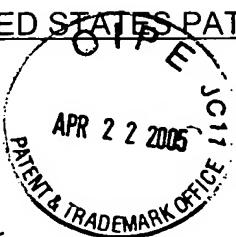
IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:

ICHIMURA et al

Serial No.: 10/520,106 ✓

Filed: January 3, 2005

For: ACTIVE RAY SENSITIVE RESIN
COMPOSITION, ACTIVE ENERGY
RAY SENSITIVE FILM AND METHOD
FOR FORMING PATTERN USING
THE FILMINFORMATION DISCLOSURE STATEMENT UNDER 37 CFR 1.97(B)(3)

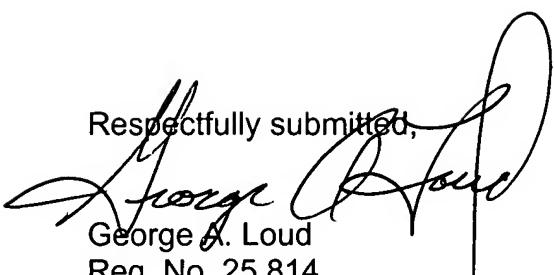
Commissioner for Patents
P.O. Box 14501
Alexandria, VA 22313-1450

Sir:

It is respectfully requested that the Examiner consider and cite of record the documents listed on the attached. Copies of three listed Japanese documents are submitted herewith, along with a published English language abstract of each.

The documents submitted here, although cited in the International Search Report, issued during the international phase of the captioned application, with substitution of US5212046 for EP423446. A copy of the International Search Report is also submitted herewith.

Respectfully submitted,



George A. Loud
Reg. No. 25,814

Dated: April 22, 2005

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Alexandria, VA 22305

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INFORMATION DISCLOSURE CITATION <i>(Use several sheets if necessary)</i>				Docket Number (Optional) OPC-C511		Application Number 10/520,106	
				Applicant(s) ICHIMURA et al			
				Filing Date January 3, 2005		Group Art Unit	
U.S. PATENT DOCUMENTS							
EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
		4,341,859	9-23-80	Keane et al			
		5,212,046	6-28-91	Lamola et al			
U.S. PATENT APPLICATION PUBLICATIONS							
*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
FOREIGN PATENT DOCUMENTS							
EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation
							YES
		09-319,079	12-12-97	Japan			
		09-203,806	8-5-97	Japan			
		07-146,549	6-6-95	Japan			
OTHER DOCUMENTS <i>(Including Author, Title, Date, Pertinent Pages, Etc.)</i>							
EXAMINER				DATE CONSIDERED			
EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.							